

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	62	substrate with(ceramic or oxide or glass or dielectric) and circuit\$4 and solder near mask and ink near jet\$4	USPAT	OR	OFF	2009/08/14 14:50
L4	129	substrate with(ceramic or oxide or glass or dielectric) and circuit\$4 and solder near mask and ink near jet\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/14 14:50
L5	33	substrate with(ceramic or oxide or glass or dielectric) and circuit\$4 and solder near mask and ink near jet\$4 and monomer	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/14 14:50
L6	0	substrate with(ceramic or oxide or glass or dielectric) and circuit\$4 and solder near mask and ink near jet\$4 and monomer and solventless	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/14 14:50
L7	1	substrate with(ceramic or oxide or glass or dielectric) and circuit\$4 and solder near mask and ink near jet\$4 and monomer and solventless	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/14 14:50
L8	14	substrate with(ceramic or oxide or glass or dielectric) and circuit\$4 and solder near mask and ink near jet\$4 and monomer and computer	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/08/14 15:13
S1	1	10/528583	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/06 18:14
S2	584	solder and actinic and acrylate and initiator and polymer	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/06 18:16

S3	451	solder and actinic and acrylate and initiator and polymer and adhesion	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/06 18:16
S4	191	solder and actinic and acrylate and initiator and polymer and adhesion near promot\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/06 18:16
S5	99	solder and actinic and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/06 18:19
S6	12	solder and actinic and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/06 18:21
S7	12	solder and actinic and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/06 18:21
S8	12	solder near mask and actinic and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/09 14:48
S9	12	solder near mask and actinic and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/09 14:48
S10	1	10/528583	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/09 14:51
S11	11	"5721007"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/09 15:22

S12	83	"5270368"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/09 15:49
S13	22	"4270985"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/09 15:57
S14	270	(UV or actinic) and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid near carboxylic	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 12:56
S15	211	(UV or actinic) and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid near carboxylic and poly	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 12:56
S16	270	(UV or actinic) and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid near carboxylic and polymer	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 12:56
S17	5460757	(UV or actinic) and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid near carboxylic and polymer circuit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 12:57
S18	59	(UV or actinic) and acrylate and initiator and polymer and adhesion near promot\$4 and surfactant and koh and acid near carboxylic and polymer and circuit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 12:57
S19	73	(UV or actinic) and acrylate and initiator and polymer and ((adhesion near promot \$4)withacid near carboxylic) and surfactant and koh and polymer and circuit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:01
S20	6	(UV or actinic) and acrylate and initiator and polymer and ((adhesion near promot \$4)with(acid near carboxylic)) and surfactant and koh and polymer and circuit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:04

S21	86513	alan.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:05
S22	2472	hopper.in.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:05
S23	34	S21 and S22	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:05
S24	2	"20050171237"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:13
S25	18	(UV or actinic) and acrylate and initiator and polymer and ((adhesion near promot \$4)with(acid near carboxylic)) and polymer and circuit\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:27
S26	6	(UV or actinic) and acrylate and initiator and polymer and ((adhesion near promot \$4)with(acid near carboxylic)) and polymer and circuit\$4 and ((isobornyl near acrylate) or(tripropylene near glycol near diacrylate) or (trimethylolpropane near ethoxylate near triacrylate))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:36
S27	6	(UV or actinic) and acrylate and initiator and polymer and ((adhesion near promot \$4)with(acid near carboxylic)) and polymer and circuit\$4 and ((isobornyl near acrylate) or(tripropylene near glycol near diacrylate) or (trimethylolpropane near ethoxylate near triacrylate))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:36
S28	17	"5089376"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 13:45

S29	17	"5089376"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 17:02
S30	4	S29 and solder and UV	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 17:02
S31	2	viscosity with("40" near degree)and solder near mask	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/10 18:05
S32	4	"5217847"	USPAT	OR	OFF	2009/02/11 11:57
S33	26	(solder near mask)and(acid near value) and koh	USPAT	OR	OFF	2009/02/11 12:09
S34	59	(solder near mask)and(acid near value) and koh	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:09
S35	56	(solder near mask)and(acid near value) with koh	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:09
S36	0	(solder near mask)and(acid near value) with koh and acrylat	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:09
S37	52	(solder near mask)and(acid near value) with koh and acrylate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:09
S38	44	(solder near mask)and(acid near value) with koh and acrylate and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:09

S39	8	(solder near mask)and(acid near value) with koh and acrylate and initiator and ink near jet	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:10
S40	2	"20030134926"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:16
S41	44	(solder near mask)and(acid near value) with koh and acrylate and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:17
S42	32	(solder near mask)and(acid near value) with koh and acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 12:18
S43	61311	(solder near mask)and (polypropylene near glycol near tetra near acrylate)with (meth near acrylic near acid) acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:51
S44	2	(solder near mask)and (polypropylene near glycol near tetra near acrylate)with (meth near acrylic near acid) and acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:51
S45	1	(solder and resist)and (polypropylene near glycol near tetra near acrylate)with (meth near acrylic near acid) and acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:52
S46	2	solder and (polypropylene near glycol near tetra near acrylate)with(meth near acrylic near acid)and acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:52
S47	1	resist and UV and (polypropylene near glycol near tetra near acrylate)with (meth near acrylic near acid) and acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:52

S48	1	resist and UV and (polypropylene near glycol near tetra near acrylate)same (meth near acrylic near acid) and acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:52
S49	2	(polypropylene near glycol near tetra near acrylate)same (meth near acrylic near acid) and acrylate with monomer and initiator	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:55
S50	2	(((((polypropylene)or(poly near propylene)) near glycol) or polypropyleneglycol) near tetra near acrylate)same (meth near acrylic near acid)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:58
S51	2	(((((polypropylene)or(poly near propylene)) near glycol) or polypropyleneglycol) near tetra near acrylate)and(meth near acrylic near acid)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:59
S52	5	(((((polypropylene)or(poly near propylene)) near glycol) or polypropyleneglycol) near tetra near acrylate)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 14:59
S53	991	(((((polypropylene)or(poly near propylene)) near glycol) or polypropyleneglycol) with (tetraacrylate or(tetra near acrylate)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:00
S54	65	(((((polypropylene)or(poly near propylene)) near glycol) or polypropyleneglycol) near4 (tetraacrylate or(tetra near acrylate)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:00
S55	34	(((((polypropylene)or(poly near propylene)) near glycol) or polypropyleneglycol) near2 (tetraacrylate or(tetra near acrylate)))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:00
S56	17	(((((polypropylene)or(poly near propylene)) near glycol) or polypropyleneglycol) near2 (tetraacrylate or(tetra near acrylate)))and solder	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:00

S57	5	"5264324"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:05
S58	19	(((((polypropylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (tetraacrylate or(tetra near acrylate)))and solder	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:08
S59	0	solder near mask and (acrylated near epoxy near monomer)with molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:26
S60	0	solder and (acrylated near epoxy near monomer)with molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:26
S61	91	solder and (acrylat\$4near epoxy near monomer)with molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:26
S62	0	solder and (acrylat\$4 near epoxy near monomer)with molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:26
S63	0	resist and (acrylat\$4 near epoxy near monomer)with molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:27
S64	4	resist and (acrylat\$4 near epoxy near monomer)same molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:27
S65	0	solder and (acrylat\$4 near epoxy near monomer)same molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:28

S66	14	solder and (acrylat\$4 near epoxy near monomer)and molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 15:29
S67	140	solder and (acrylat\$4 near epoxy with monomer)and molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 16:16
S68	22	solder and (acrylat\$4 near epoxy) with monomer with molecular near weight	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/11 16:17
S69	135	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (acrylate or(tetra near acrylate)))and solder	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:13
S70	19	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (acrylate or(tetra near acrylate)))and solder near mask	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:13
S71	14	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (acrylate or(tetra near acrylate)))and solder near mask and (meth near acrylic near acid)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:13
S72	2	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (acrylate or(tetra near acrylate)))and solder near mask same (meth near acrylic near acid)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:13
S73	0	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (tetraacrylate or(tetra near acrylate)))and solder near mask and (meth near acrylic near acid)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:17

S74	0	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (tetracrylate or(tetra near acrylate)))and solder near mask and (meth near acrylic near acid)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:17
S75	0	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (tetracrylate or(tetra near acrylate)))and solder near mask and (meth near acrylic near acid)and adhesion	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:18
S76	12	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 (acrylate or(tetra near acrylate)))and solder near mask and (meth near acrylic near acid)and adhesion	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 13:18
S77	12	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 acrylates)and solder near mask and (meth near acrylic near acid)and adhesion	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 14:16
S78	0	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 acrylates)with adhesion and solder near mask and (meth near acrylic near acid)and adhesion	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 14:18
S79	0	(((((propylene)or(poly near propylene)) near3 glycol)or polypropyleneglycol) near2 acrylates)same adhesion and solder near mask and (meth near acrylic near acid)and adhesion	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/02/13 14:18
S80	5	solventless with solder near mask	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/13 10:38
S81	5	solventless with solder near mask	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/13 10:38

S82	2	"20030203994"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/08/14 12:28
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